AMENDMENTS TO THE CLAIMS:

This listing of claims will replace all prior versions and listings, of claims in the application:

LISTING OF CLAIMS:

1. (Currently Amended) A method of making a lithographic printing plate from a heat-sensitive pre-sensitized plate of a positive-working mode for lithographic printing comprising the steps of:

exposing the heat-sensitive pre-sensitized plate to light, and

developing the plate using an alkaline developing solution comprising (a) at least one surfactant selected from the group consisting of anionic surfactants and ampholytic surfactants in an amount of 0.001 to 10% by weight, and (b) at least one salt selected from the group consisting of alkali metal salts and salts of an ammonium cation, wherein the pre-sensitized plate comprises a substrate, a lower layer which comprises a water-insoluble and alkali-soluble resin, and an upper heat-sensitive layer which comprises a water-insoluble and alkali-soluble resin and an infrared absorption dye and exhibits an elevated solubility with respect to alkaline aqueous solutions when heated, said lower layer and said upper heat-sensitive layer being located on the substrate in this order.

- 2. (Canceled)
- 3. (Currently Amended) The method of claim [[2]] 1 wherein the amount of (a) at least one surfactant selected from the group consisting of anionic surfactants

Attorney's Docket No. <u>018995-736</u> Application No. <u>10/658,399</u>

Page 3

and ampholytic surfactants in the developing solution is in the range of 0.005 to 1%

by weight.

4. (Original) The method of claim 3 wherein the amount of (a) at least one

surfactant selected from the group consisting of anionic surfactants and ampholytic

surfactants in the developing solution is in the range of 0.01 to 0.5% by weight.

5. (Original) The method of claim 1 wherein the amount of (b) at least one

salt selected from the group consisting of alkali metal salts and salts of an

ammonium cation in the developing solution is in the range of 0.01 to 1 mol/liter in

terms of the alkali metal and/or ammonium cation.

6. (Original) The method of claim 5 wherein the amount of (b) at least one

salt selected from the group consisting of alkali metal salts and salts of an

ammonium cation in the developing solution is in the range of 0.05 to 0.5 mol/liter in

terms of the alkali metal and/or ammonium cation.

7. (Original) The method of claim 1 wherein the ratio of the amount of (a) at

least one selected from an anionic surfactant and an ampholytic surfactant in terms

of A (gram/liter) to the amount of (b) at least one selected from an alkali metal and

an ammonium cation in terms of B (mol/liter) in the developing solution: A/B is in the

range of from 0.01 to 100.

8. (Original) The method of claim 7 wherein the A/B is in the range of from

0.1 to 50.

Attorney's Docket No. <u>018995-736</u>
Application No. <u>10/658,399</u>

- 9. (Original) The method of claim 1 wherein (b) at least one salt selected from the group consisting of alkali metal salts and salts of an ammonium cation is selected from halide, sulfate, nitrate, phosphate, carbonate, borate, formate, acetate, propionate, maleate, lactate, levulinate, malonate, adipate, fumarate, citrate, and malate.
- 10. (Original) The method of claim 9 wherein (b) at least one salt selected from the group consisting of alkali metal salts and salts of an ammonium cation salt is selected from chloride salt, nitrate, sulfate, phosphate, carbonate, borate, acetate and citrate.
- 11. (Original) The method of claim 1 wherein the anionic surfactant is selected from fatty acid salts, abietates, hydroxyalkanesulfonates, alkanesulfonates, alkyldiphenyl ether sulfonates, diphenyl ether disulfonates, dialkylsulfosuccinate ester salts, linear alkylbenzenesulfonates, branched alkylbenzenesulfonates, alkylnaphthalenesulfonates, alkylphenoxy polyoxyethylenepropylsulfonates, polyoxyethylene alkylsulfophenyl ether salts, sodium salts of N-methyl-N-oleyltaurine, disodium salts of N-alkylsulfosuccinic monoamide, petroleum sulfonates, sulfated tallow oil, sulfates of fatty acid alkyl esters, alkyl sulfates, polyoxyethylene alkyl ether sulfates, fatty acid monoglyceride sulfates, polyoxyethylene alkylphenyl ether sulfates, polyoxyethylene styrylphenyl ether sulfates, alkyl phosphates, polyoxyethylene alkyl ether phosphates, polyoxyethylene alkylphenyl ether phosphates, polyoxyethylene maleic anhydride

copolymers, partially saponified olefin - maleic anhydride copolymers, and condensates of naphthalenesulfonate and formalin.

- 12. (Currently Amended) The method of claim1 claim1 wherein the anionic surfactant is selected from carboxylic acid type surfactants and sulfonic acid type surfactants.
- 13. (Original) The method of claim 12 wherein the anionic surfactant is selected from fatty acid salts, abietates, hydroxyalkanesulfonates, alkanesulfonates, alkyldiphenyl ether sulfonates, diphenyl ether disulfonates, dialkylsulfosuccinate ester salts, olefin sulfonates, linear alkylbenzenesulfonates, branched alkylbenzenesulfonates, alkylnaphthalenesulfonates, alkylphenoxy polyoxyethylene propylsulfonates, polyoxyethylene alkylsulfophenyl ether salts, disodium salts of N-alkylsulfosuccinic monoamide, petroleum sulfonates, and condensates of naphthalenesulfonate and formalin.
- 14. (Original) The method of claim 13, the anionic surfactant is selected from diphenyl ether disulfonate salts represented by the following formula (I):

$$R^1$$
 O
 R^2
 SO_3M
(I)

wherein R¹ and R² each represents a hydrogen atom or a linear or branched alkyl group, and M represents a monovalent alkali metal.

- 15. (Currently Amended) The method of claim 1 wherein the ampholytic surfactant is selected from amino acid type-ampholytic surfactants and betaine type-ampholytic surfactants surfactants.
- 16. (Original) The method of claim 1 wherein the ampholytic surfactant is selected from alkylamino dicarboxylic acids and salts thereof represented by the following formula (II):

$$R_1$$
-N (CH₂)_pCOOR₃ (II)

wherein R_1 represents an alkyl group having 4 to 30 carbon atoms, R_2 and R_3 each represents a hydrogen atom or a monovalent alkali metal, and n and p each represents an integer from 1 to 10.